M-Speed HF

Copper Treatment for High Speed Innerlayers

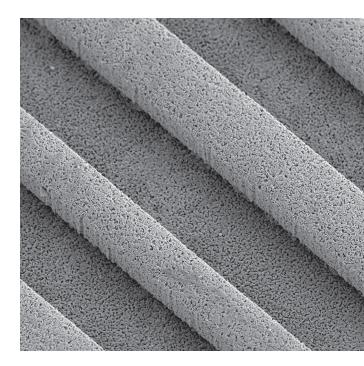
No Limits for High Speed, High Frequency Applications.

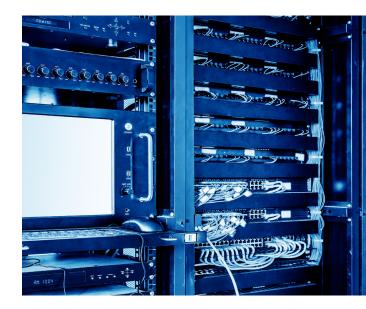
M-Speed HF is an alternative oxide process developed to meet the needs of next generation high speed data rate requirements. Delivering the renowned reliability of MacDermid Alpha chemistry technology in a new low etch process. Reduced signal loss and high adhesion without compromise. The unique low etch process provides a low profile surface topography to optimize maximum signal integrity for high speed applications and uniform trace geometry for controlled impedance designs. The M-Speed HF process offers superior adhesion and thermal-mechanical reliability despite the low peak to valley roughness.

The M-Speed HF system achieves industry-leading performance by utilizing standard alternative oxide process equipment in combination with a novel post-dip process. The process is compatible with virtually all laminate materials, and creates exceptional adhesion to low and ultra-low loss dielectric systems. To meet the challenges of next generation digital designs, choose M-Speed HF.

KEY FEATURES

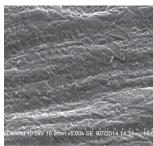
- Reduced copper roughness for reduced signal attenuation
- Precision etch rates for controlled impedance designs
- Environmentally friendly reduced chemical consumption and waste
- Superior reliability for high layer-count designs





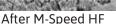


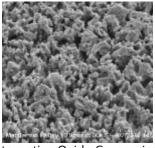
Complete Chemical Process For High Frequency Printed Circuit Board Applications



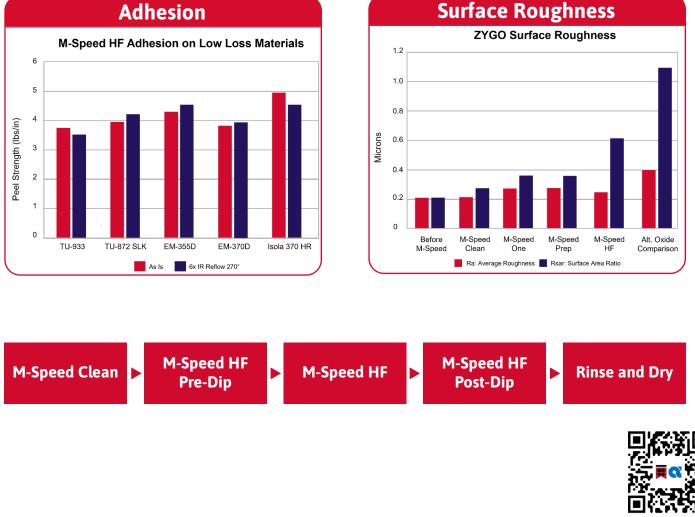
Before M-Speed







Alternative Oxide Comparison



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